Physical Properties of Chitosan Films Obtained after Neutralization of Polycation by Slow Drip Method

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Abstract

The development of new materials from biodegradable constituents is enticing for applications in bioelectronics and biomedicine, due to their considerable durability, versatility and biodegradability. The present work aims to determine the chemical and physical properties of chitosan membranes after neutralization of the polycation solution. This work was divided into two stages: solubilization and neutralization. In the first stage, the chitosan was solubilized with three different concentrations of acetic acid (1%, 0.8% and 0.5%) in order to evaluate whether the acid affected the physical-chemical properties of the films. In the second stage, the chitosan polycation was neutralized with two strong bases (NaOH and KOH) using three different molar concentrations, by the slow drip method for obtaining films with pH values close to neutrality. The characterization of the membranes obtained from casting method showed that the different concentrations of acetic acid did not affect the physical-chemical properties of the films. In contrast, the neutralization process did affect their properties, and in particular, different behaviors were observed depending on the type of base used for neutralization. More ductile and plasticity were obtained in the films when the polycation was neutralized with KOH, whereas the films neutralized with NaOH exhibited a more fragile behavior.

Keywords
Biodgradable Film, Chitosan, Hydrogel, Mechanical Properties, Swelling

1. Introduction

The use of biological materials in the development of components for electronic application has attracted consi-
derable interest among scientists because of the advantages it offers to the device such as: simple processing, low manufacturing cost, versatile molecular design and the ability to control physicochemical properties. A number of devices including electrochemical biosensors, load cells, electroluminescent devices and Schottky diodes were fabricated and tested using conductive polymers [1]. New materials and components for industrial applications should possess special physical characteristics such as durability, resistance to handling and versatility of use.

Most polymers demonstrate a resistance to the passage of electric current, exhibiting the behavior of electrical insulators. Chitosan is the deacetylated form of chitin, which is a linear type of biopolymer acetyl-D-glucose with the ability to act as a proton conductive matrix. This property is a direct result of the lone pair associated with the amine and hydroxyl groups within the chitosan monomer; making the material a suitable candidate for a solid electrolyte polymer [2]-[6].

Chitosan is a natural polymer that has unique properties, primarily its non-toxicity, biodegradability and biocompatibility [6]. It can be a suitable matrix for the development of biosensors by positioning of the membranes and immobilizing biological materials (enzymes such as horseradish peroxidase or HRP) on the surface of the matrix. The chitosan powder is solubilized in a solution of acetic acid (1%). As a result, the membrane has a pH value of approximately 4.3, which can affect the enzymatic kinetics negatively since maximum enzymatic activity of HRP occurs for pH values in the range of 5 - 6 [7].

The development of enzymatic biosensors demands materials with certain characteristics for the support of the immobilization of enzymes. In the case of biopolymer matrices, it is necessary to remove traces of solvent in the film, other than the free hydroniums present in the polymer matrix, because of a pH value near neutrality and bioreceptors with a high fixing ability [8]. To do so, the neutralization process of the membrane removes residual acid and regenerates the NH2 groups of the chitosan making the hydrophilic surface of the film and cell compatible [9].

This study aims to characterize the physical-chemical behavior, and eventual industrial applications, of chitosan membranes neutralized, obtained from the solubilization of chitosan powder in three concentrations of acetic acid (1%, 0.8% and 0.5%). The solution of polycation will be neutralized by the method of slow dripping, employing two strong bases, sodium hydroxide (NaOH) and potassium hydroxide (KOH) in three molar concentrations (0.5, 1 and 5 M).

2. Materials and Methods

2.1. Materials

Chitosan derived from crab shell with a deacetylation degree greater than 85% and average molecular weight, was purchased from Sigma Co. (Brazil). Glacial acetic acid was purchased from NEOBIO (Brazil). Sodium and Potassium hydroxide (analytical grade) was purchased from SYNTH (Brazil). All other reagents were local products of analytical grade.

2.2. Production of Neutralizing Solutions

Neutralizing solutions of sodium and potassium hydroxide were produced from the dissolution of bases in deionized water (18.2 mΩ-cm @ 25°C) in three molar concentrations (0.5, 1 and 5 M).

2.3. Production of Buffer Solution

The phosphate buffered saline (PBS) solution was produced according to a previously published report [10]. Buffer solutions with different pH’s (pH5 and pH9) were prepared from the mixture of hydrated monosodium phosphate (NaH2PO4.H2O) and disodium phosphate heptahydrate (Na2HPO4.7H2O). For the preparation of phosphate buffer solution at pH 5, 1.361 g of NaH2PO4.H2O and 0.036 g of Na2HPO4.7H2O were used; for the preparation of the solution at pH 9 0.01 g of NaH2PO4.H2O and 2.660 g of Na2HPO4.7H2O were used for 100 ml of solution.

2.4. Obtaining Films

2.4.1. Production of Chitosan Polycation

The powdered chitosan (1% w/v) with a degree of deacetylation of 85% and an average molecular weight sup-
plied by Aldrich Chemical Company Ltd. (Brazil) was solubilized in deionized water with different concentrations of acetic acid (1%, 0.8% and 0.5%) under constant stirring until complete dissolution of the chitosan. The viscous solution of the polycation was filtered by vacuum using a filter with a pore size of 1.2 µm in order to remove insoluble particles and impurities present in the chitosan powder; the process of filtered were performed one time.

The polycationic solutions were classified according to acetic acid concentration used, and type/concentration of base used to neutralize the polycation. Table 1 illustrates the sorting method and the name assigned to each sample, where white corresponds to the control, or no-neutralized, sample.

### 2.4.2. Neutralization of the Chitosan Polycation

The chitosan polycation was neutralized by slow drip of neutralizing solution (NaOH and KOH in different molar concentration) at the rate of one drop of solution per minute (1 drop/minute) until reaching a pH of 6.0 under constant agitation. According to reported by [6] [11], the pK of chitosan polycation is around 6.3 due to the presence of amino groups. The neutralization process and slow dripping can be observed in Figure 1.

### 2.4.3. Production of Chitosan Films

The neutralized films were produced by casting technique. The solubilization of chitosan in acetic acid was performed with constant stirring, using 1 g quitosana/100 ml of solution (acetic acid at various concentrations). The polycation chitosan was neutralized under constant stirring with continuous pH control due to the constant drip of neutralizing solution, which was previously obtained from the solubilization of bases in deionized water at specific molar concentrations (0.5, 1 and 5 M). The neutralization process brought the pH of the polycation to 6.0. After neutralizing the polycation, the solution was kept in an ultrasound bath (Ultra Cleane 1400°, Unique) for 5 minutes. The solutions were spread on petri dishes (Bioplass) with the same amount of mass (25 g) to ensure a constant thickness. The solutions dispersed and settled, and then the petri dishes were dried in a forced circulation oven (MA 037, Marconi) at 30°C for 48 hours. After that time, the films were placed in desiccators with silica gel until the characterization process.

<table>
<thead>
<tr>
<th>Table 1. Classification of samples to be processed.</th>
</tr>
</thead>
<tbody>
<tr>
<td>Concentration of acetic acid used</td>
</tr>
<tr>
<td></td>
</tr>
<tr>
<td>HAc 1%</td>
</tr>
<tr>
<td>HAc 0.8%</td>
</tr>
<tr>
<td>HAc 0.5%</td>
</tr>
</tbody>
</table>

Figure 1. Slow drip of neutralizing solution for neutralization process of chitosan polycation.
2.5. Characterization of Neutralized Films

2.5.1. Ultraviolet Spectroscopy (UV-Vis)
The chitosan neutralized polycation was analyzed from the changes presented in the links in the presence of bases, for analyzed this changes respect to standard samples was employed a Beckman Coulter DU 800, thereby colloids were treatment for a range of wavelengths between 200 and 800 nm. Each determination was done in triplicate.

2.5.2. FT-IR Spectroscopy
The films obtained after the interaction between the chitosan polycation and the neutralized solutions were evaluated with a Perkin Elmer spectrophotometer (Spectrum One FT-IR) equipped with UATR according to a previously published report [12]. Scans (16 scans in point) were performed in the spectral range of 400 - 4000 cm$^{-1}$ with a resolution of 2 cm$^{-1}$. The results were collected and treated with Spectrum One software (Spectrum One, version 5.3).

2.5.3. X-Ray Diffraction
The neutralized films crystallinity was compared with the standard film crystallinity from the X-ray diffraction (Rigaku Geigerflex Powder Diffractometer) with Ni-filtered, Cu radiation, operated at 30 kV and 30 mA. Diffraction patterns were recorded over a range of diffraction angles $2\theta = 5^\circ$ to $25^\circ$ with a scan rate of $1^\circ$ (2$\theta$) per minute and a step size of 0.1$^\circ$ (2$\theta$).

2.5.4. Thickness
The thickness of the films was determined using a digital micrometer (Mitutoyo) with range of 0 - 25 mm and accuracy of 0.001 mm. Values are presented as the average of ten measurements made randomly along each sample evaluated by performing triplicate for each film type.

2.5.5. Swelling
The films samples were cut into a 10 × 10 mm square. The dried and stabilized samples, which were in a desiccator for 72 hours, were removed and weighed (AUY220 Shimadzu, analytical scale) to determine the weight of the dry sample. After weighing, the samples were immersed in solutions of phosphate buffer with respective pH values of 5 and 9. To determine the percentage of swelling, it was necessary to collect data for a period of 72 hours beginning data collection every 15 minutes in an hour, and every hour until at least 4 hours had passed. After this time, the collection of date was made every 4 hours over 8 hours and then performed every 8 hours over the first 24 hours. Collecting data every 24 hours during the 72 hours of the test is finished.

To establish the percentage of swelling it is necessary to relate the dry weight of the sample to the weight of the hydrated sample (Equation (1)). This was achieved by taking the samples from the swelling solution every time data collection began and removing excess moisture from the film surface with pre-moistened filter paper, ensuring only the absorption of moisture from the surface of the film.

$$S(t) = \left( \frac{W_f}{W_0} - 1 \right) \times 100$$

where $S(t)$ is the percent of swelling, $W_f$ the final weight and $W_0$ the initial film weight.

2.5.6. Mechanical Properties
The mechanical properties of the films were evaluated by Stress-Strains curves (The Young’s modulus E, the strain at break, the stress at break and energy required to fracture) using a texturometer TA.XT2i (TA Instruments).

To determine the mechanical properties by tensile stress-strain test, the films were cut into strips of 15 mm wide and 80 mm long; then the films were stored in a desiccator with silica gel for seven days. The strips were fixed in the grips of a texturometer with an initial height of 50 mm (lo) and stretched using a crosshead speed of 0.9 mm/s, the films were stretched to failure, generating a stress (MPa) strain (%) curve. The analysis was performed in triplicate.

2.5.7. Scanning Electron Microscopy
The surface and internal microstructure, of chitosan films were analyzed by the scanning electron microscope
(SEM) (Hitachi, TM30000) at 15 kV. For analysis, the samples were pre-conditioned in a desiccator with silica gel under vacuum. To analyze the internal microstructure the films were freeze-fractured after immersion in liquid nitrogen.

3. Results and Discussion

3.1. Neutralization of Chitosan Polycation

The process of neutralizing the polycation without reaching the pKa (6.3) of chitosan \[6\] \[11\] using the sodium and potassium bases in different concentrations by the slow drip method produced films with physical and chemical properties that can have a range of uses. Among these is developing an ideal polymeric matrix for the immobilization of biological receptors, which are the base of biosensors. The solutions of the polycation showed no significant difference regarding their color, since they all had similar transparency when different concentrations of acetic acid were used in the solubilization of chitosan and when different concentrations of the bases were used to neutralize polycation. In contrast, the films did show differences, since neutralized films with sodium have a white color whereas the films neutralized with potassium exhibit a transparency similar to films without treatment. This difference may be associated with different ionic radius of sodium (Na\(^+ = 0.95\) Å) and potassium (K\(^+ = 1.33\) Å), present in the solutions of neutralization. Furthermore, the white color in the films obtained from the chitosan polycation neutralized with solutions of sodium hydroxide is linked directly to formation of sodium acetate on the membrane surface, while the membranes obtained from the polycation neutralized with potassium could form the acetate within the membrane structure. The color of the films is shown in Figure 2.

3.2. Characterization of Neutralized Chitosan Films

3.2.1. Ultraviolet Spectroscopy (UV-Vis)

The solubilized chitosan polycation in three concentrations of acetic acid and neutralized with two different bases with three molar concentrations were characterized by UV-vis spectroscopy in a wavelength range of 200 to 600 nm. The spectra obtained are shown in Figure 3, characterized by an increase in absorption near the 240 nm wavelength directly related to the increase in concentration of acetic acid to solubilize the chitosan. The observed displacement in wavelength may be associated with a variation in crystallinity within the polymer matrix. The band of 225 nm in the UV-vis spectrum is attributed to ionic linkages (\(\eta \rightarrow \pi\)) that are directly affected by the base used for neutralization of the polycation chitosan when it is solubilized with a percentage of acetic acid greater than or equal to 1%. The absorption near to 280 nm is attributed to unsaturated bonds of covalent linkages (\(\pi \rightarrow \pi\)) principally C-O, which increases the absorption intensity with increased chitosan concentration \[13\] \[14\].

![Figure 2. Chitosan films 1% without treatment (A), NaOH neutralized (B), KOH Neutralized (C).](image)
3.2.2. Spectroscopy Fourier Transform Infrared (FT-IR)
The chitosan films showed characteristic bands at 3450 cm$^{-1}$ (O-H stretching group), 3299 cm$^{-1}$ (N-H stretching group), 2898 cm$^{-1}$ (C-H stretching group), 1655 cm$^{-1}$ (amide I band), 1560 cm$^{-1}$ (amide II band, N-H stretching), 1410 cm$^{-1}$ (C-H asymmetric group and CH$_2$ bending), 1310 cm$^{-1}$ (amide III band), 1150 cm$^{-1}$ (skeletal vibration involving the stretching bridge C-O-C) and 1080 cm$^{-1}$ (skeletal vibration of pyranose chitosan structure) [15].

The spectra of the films obtained by solubilized chitosan with different concentration of acetic acid did not show differences in the characteristic peaks, as shown in Figure 4. However, it was observed that the reference peaks of chitosan are affected when the polycation is neutralized with KOH particularly in reference to those neutralized with NaOH and to films without treatment (Figure 5). Peaks of films neutralized with potassium exhibit a higher intensity compared to films neutralized with sodium, which in turn exhibit a higher intensity than films without treatment.

According to reported by [16] characteristic peaks for protonated amino groups (NH$_3^+$) in the chitosan structure are near to 1588 cm$^{-1}$, as a result is possible evaluate the degree of protonation of amine through the intensity of the peak as it appears on the FT-IR spectrum. In a similar manner, establishing the crystallinity degree of structure could be identified from the peak intensity 1410 cm$^{-1}$, which shows stability vibration of the amorphous phase of amide III (CH$_2$) [17].

3.2.3. X-Ray Diffraction
According to [18] the crystal structure of chitosan is maintained primarily by intramolecular and intermolecular
hydrogen bonding, established by an amino group at C-2 and a hydroxyl group at C-3, for the latter formed between two hydroxyl groups at C-6 and C-3, carbon positions on either side of an absorbed molecule of water. Typically, chitosan membranes exhibit two characteristic peaks, which are related to two types of crystals that are present in the polymer matrix. The first peak has a strong reflection at $2\theta = 11.5^\circ$ and is cataloged as crystal I form with an orthorhombic configuration and having a unit cell of $a = 7.76$ Å, $b = 10.91$ Å, $c = 10.30$ Å, $\beta = 90^\circ$. The second peak has a reflection at $2\theta = 20.1^\circ$ associated with the crystal II form also with an orthorhombic...
configuration and a unit cell of $a = 4.4 \, \text{Å}$, $b = 10.0 \, \text{Å}$, $c = 10.30 \beta = 90^\circ$ (the fiber axis). The size of the unit cell of the crystal I is bigger than the crystal II cell, due to the crystal I unit cell being constituted by two monomeric units along the main axis of the polymer chain, while the crystal II has only one monomeric unit along the principal axis [19].

The different concentrations of acetic acid have no influence on the formation of characteristic crystals in the chitosan membranes, presenting both characteristic peaks at $2\theta = 11.5^\circ$ and $2\theta = 20.1^\circ$.

The neutralizing process of chitosan polycation with sodium hydroxide and potassium hydroxide at concentrations of 0.5, 1 and 5 M established a change in the conformity of the structure of crystal type I in the polymorph of chitosan. Figure 6(A) and Figure 6(B) shows the analysis of X-ray diffraction of neutralized chitosan membranes, showing a reduction of the peak $2\theta = 11.5^\circ$ which is characteristic of the hydrated part (tendon) in the chitosan polymeric structure of membranes [16]. According to reported previously [20] the modification of the peak related to the morphology of the crystal type I in the chitosan polymeric network structure is directly connected with the loss of hydrogen bonding and deprotonation of the amino groups in the chitosan polymer structure after the neutralization treatment.

### 3.2.4. Thickness

The average values of thickness after the neutralization process of chitosan polycation are shown in Figure 7. Film thickness was increased depending on the type of base used, exhibiting greater thickness for films neutralized with KOH in comparison with the films neutralized with NaOH. The films neutralized with NaOH showed a thickness increase of 14% compared to films without treatment, while the films neutralized with KOH exhibited an increase of 68% with respect to films without treatment and a difference of 32% in relation to the film neutralized with NaOH. The thickness increase is directly related to the possible formation of acetate. In the case of membranes obtained by polycation neutralization with sodium hydroxide, sodium acetate formed on the membrane surface, changing both color and thickness of the film; whereas the membranes obtained by chitosan polycation neutralization with potassium hydroxide showed a greater thickness compared to other films, because of the formation of acetate in the structure of the membrane. Similar results were reported by researchers who have established a significant increase in thickness after neutralization process, besides dopant incorporation in chitosan films [21]-[23].

### 3.2.5. Swelling

The resistance of polymers to high moisture environments is directly related to the presence of hydrophilic groups, cross-linking degree of the molecules and presence of ionic polar groups in the structure of chitosan films, which allow them to have a greater sensitivity to pH medium with which the films have an interaction [24].
Swelling evaluation in acidic and basic media allows the establishment of weight loss and gain of moisture in chitosan films after the neutralization process. The degree of swelling in the films was calculated from equation 1 and shown in Figure 8 and Figure 9.

Figure 8 shows the swelling of the neutralized chitosan films with NaOH at three different concentrations. They were immersed in a phosphate buffer solution at pHs of 5 and 9. After the initial weight gain due to moisture absorption in less than three hours, the films tend to stabilize with time. The films without treatment exhibit a greater stability in relation to neutralized films, since the latter have two behaviors, an increasing curve due to moisture absorption and a decreasing standard attributed to weight loss during the stabilization of the films in buffer solution. The observed pattern is directly related to the dipping solution pH, as well as the concentration and type of base used to neutralize the polycation. The neutralized films with NaOH showed moisture absorption and weight loss more stable over time for 5M concentrations.

Neutralized films with KOH and immersed in phosphate buffer pH 9 showed a considerable mass loss in relation to the same samples immersed in phosphate buffer pH 5. Again this behavior can be explained in terms of electrostatic affinity between the aqueous medium and the modified chitosan structure, as the remaining potassium ions in the three-dimensional network of chitosan enable a high mass transfer between films and the reaction medium (Figure 9). Chitosan is a polysaccharide containing amino groups with pKa near to neutrality [24] therefore at pH < 5.0 the electrostatic repulsion between the protonated primary amino groups (\( \text{NH}_2^+ \)) exceeds the electrostatic interactions with the COO\(^-\) groups, inducing the dissolution of the chitosan films without treatment.

3.2.6. Mechanical Properties

The mechanical properties such as tensile strength (\(\sigma\)) (the maximum stress that the film can withstand, MPa), elongation at break (\(\varepsilon_{\text{max}}\)) (maximum variation of strain by the film before being broken, in %); modulus of elasticity E (which is a measure of the stiffness of the film in MPa) and energy to break (KJ/m²) (energy required to break the film), were considered as the principal parameters of interest in this study and the results were summarized in Table 2.

The capacity of tensile strength is directly linked with the cohesive forces of the matrix polymer because of intermolecular interactions, and is affected by the concentration and type of base used in neutralization process [25].

The improvement of some mechanical characteristics in neutralized chitosan films as ductility is linked to the presence of bases and their different concentrations. Figure 10 shows the tensile strength of chitosan films...
Figure 8. Swelling kinetics of neutralized chitosan films with NaOH into phosphate buffer pH5 (A) and phosphate buffer pH9 (B) at 37.5°C by 72 h. (□) Qs W0, (○) QsSo0.5, (Δ) QsSo1.0, (◊) QsSo5.0.

Figure 9. Swelling kinetics of neutralized chitosan films with KOH into phosphate buffer pH5 (A) and phosphate buffer pH9 (B) at 37.5°C by 72 h. (□) Qs W0, (○) QsPo0.5, (Δ) QsPo1.0, (◊) QsPo5.0.

without and after the neutralization process, establishing that chitosan films by solubilized at a concentration of 0.5% of acetic acid and neutralized with potassium hydroxide at concentration of 0.5 M exhibit greater resistance
Figure 10. Comparison of tensile testing results of chitosan films without neutralizing (Qs W1) and neutralized films using NaOH and KOH at different concentrations, solubilized with acetic acid at concentrations of (\(\parallel\)) 1%, (x) 0.8%, (\(\backslash\)) 0.5%.

Table 2. Mechanical properties of chitosan films after process of neutralization with NaOH and KOH bases.

<table>
<thead>
<tr>
<th>Codification of samples</th>
<th>Tensile strength ((\sigma)) (MPa)</th>
<th>Elongation at break ((\varepsilon)) (%)</th>
<th>Elastic Modulus (E) (MPa)</th>
<th>Energy to break (KJ/m²)</th>
</tr>
</thead>
<tbody>
<tr>
<td>QsW1</td>
<td>98.82 ± 0.72</td>
<td>6.28 ± 0.07</td>
<td>2442.61 ± 198.63</td>
<td>195.371 ± 17.45</td>
</tr>
<tr>
<td>QsSo0.5</td>
<td>48.43 ± 0.68</td>
<td>2.48 ± 0.07</td>
<td>2463.02 ± 185.32</td>
<td>25.907 ± 4.54</td>
</tr>
<tr>
<td>QsSo1.0</td>
<td>44.74 ± 0.98</td>
<td>2.17 ± 0.09</td>
<td>2658.67 ± 219.63</td>
<td>20.864 ± 3.58</td>
</tr>
<tr>
<td>QsSo5.0</td>
<td>35.02 ± 0.51</td>
<td>1.74 ± 0.05</td>
<td>3076.93 ± 275.53</td>
<td>11.559 ± 2.21</td>
</tr>
<tr>
<td>QsPo0.5</td>
<td>12.25 ± 0.95</td>
<td>3.68 ± 0.07</td>
<td>660.52 ± 89.63</td>
<td>14.433 ± 1.08</td>
</tr>
<tr>
<td>QsPo1.0</td>
<td>20.22 ± 0.85</td>
<td>6.45 ± 0.09</td>
<td>807.79 ± 97.45</td>
<td>45.643 ± 3.45</td>
</tr>
<tr>
<td>QsPo5.0</td>
<td>19.82 ± 0.94</td>
<td>6.49 ± 0.07</td>
<td>816.14 ± 92.85</td>
<td>44.918 ± 2.18</td>
</tr>
<tr>
<td>QsW2</td>
<td>107.55 ± 2.11</td>
<td>6.42 ± 0.02</td>
<td>3374.35 ± 212.28</td>
<td>239.737 ± 19.87</td>
</tr>
<tr>
<td>QsSo0.5</td>
<td>76.1 ± 1.08</td>
<td>2.25 ± 0.03</td>
<td>4329.78 ± 282.81</td>
<td>39.637 ± 1.45</td>
</tr>
<tr>
<td>QsSo1.0</td>
<td>79.5 ± 1.17</td>
<td>3.73 ± 0.02</td>
<td>3597.5 ± 231.78</td>
<td>83.865 ± 4.85</td>
</tr>
<tr>
<td>QsSo5.0</td>
<td>89.34 ± 1.51</td>
<td>4.1 ± 0.02</td>
<td>3265.4 ± 210.48</td>
<td>101.022 ± 9.77</td>
</tr>
<tr>
<td>QsPo0.5</td>
<td>75.28 ± 1.23</td>
<td>2.72 ± 0.05</td>
<td>3578.15 ± 222.22</td>
<td>44.054 ± 1.54</td>
</tr>
<tr>
<td>QsPo1.0</td>
<td>46.51 ± 0.95</td>
<td>4.34 ± 0.04</td>
<td>2031.49 ± 182.28</td>
<td>68.573 ± 2.87</td>
</tr>
<tr>
<td>QsPo5.0</td>
<td>80.16 ± 1.03</td>
<td>3.99 ± 0.09</td>
<td>3535.9 ± 242.44</td>
<td>86.524 ± 3.24</td>
</tr>
<tr>
<td>QsW3</td>
<td>110.11 ± 2.23</td>
<td>4.72 ± 0.04</td>
<td>3291.74 ± 187.91</td>
<td>154.28 ± 4.69</td>
</tr>
<tr>
<td>QsSo0.5</td>
<td>102.12 ± 2.35</td>
<td>4.5 ± 0.05</td>
<td>3878.32 ± 198.15</td>
<td>136.069 ± 4.84</td>
</tr>
<tr>
<td>QsSo1.0</td>
<td>96.02 ± 1.23</td>
<td>4.55 ± 0.03</td>
<td>3962.47 ± 201.11</td>
<td>136.183 ± 4.12</td>
</tr>
<tr>
<td>QsSo5.0</td>
<td>86.92 ± 1.12</td>
<td>5.42 ± 0.04</td>
<td>4083.23 ± 231.35</td>
<td>174.576 ± 5.14</td>
</tr>
<tr>
<td>QsPo0.5</td>
<td>114.83 ± 2.34</td>
<td>3.62 ± 0.08</td>
<td>4464.65 ± 242.91</td>
<td>119.187 ± 3.87</td>
</tr>
<tr>
<td>QsPo1.0</td>
<td>63.54 ± 0.93</td>
<td>2.64 ± 0.09</td>
<td>3217.24 ± 211.51</td>
<td>37.281 ± 2.69</td>
</tr>
<tr>
<td>QsPo5.0</td>
<td>88.49 ± 1.03</td>
<td>2.76 ± 0.04</td>
<td>3974.87 ± 271.08</td>
<td>61.092 ± 3.01</td>
</tr>
</tbody>
</table>

Data followed by their standard errors.
to strain. Similar results were obtained by [26] in stress test and the results attested to an improvement in ductility of the material due to the porosity of the membrane made by small crystals of KOH remaining in the chitosan films. Figure 11 shows the strain of neutralized film, showing that the samples neutralized with KOH have a higher strain compared with samples neutralized with NaOH and without treatment samples. [27] Assert that, the use of plasticizers in chitosan films increase the ductility of the material, reducing the tensile strength and increasing elongation of the membrane. In Figure 10, can be seen that the samples solubilized with acetic acid at 1% and neutralized with KOH 1 M and 5 M have the lowest tensile strength, whereas in Figure 11 these same samples show higher elongation percentage, which can be attributed to possibility of KOH have a plasticizing capacity in chitosan films.

The neutralization process leads to structural changes in the chitosan chains, which have impact on the physical characteristics such as the elastic modulus (Young) and energy (KJ/m²) required for rupture. The results show that the membranes neutralized with NaOH exhibit an increase in elastic modulus compared to membranes neutralized with KOH. At the same time, membranes neutralized with NaOH have a lower deformation compared to membranes neutralized with KOH (Table 2); [26] obtained similar results, which established that the modulus of elasticity and the energy needed to break the membranes decrease with the presence of KOH within the membrane. However, [16] obtained an increase in the elasticity modulus in membranes neutralized with NaOH. Based on the analysis it is clear that the films neutralized with NaOH exhibit a fragile behavior whereas films neutralized with KOH exhibit a ductile behavior.

### 3.2.7. Scanning Electron Microscopy

The surfaces of the membranes without neutralization (Figure 12(A)) exhibit a regularity and uniformity, which is linked to the drying process. The morphology of the fracture (Figure 12(B)) shows a homogeneous, dense and cohesive structure, typical of chitosan films without any processing [25].

The membranes obtained after neutralization show changes such as the presence of crystals of sodium and potassium on the surface (Figures 13(A)-(D)). Furthermore the cross section of the membrane after fracture exhibits changes, such as the presence of pores and laminar formats (Figure 14(A) and Figure 14(D)), when compared to films without neutralizer which exhibit a dense and cohesive morphology (Figure 12(A)). These microstructural changes are the reason there were also significant changes in the mechanical properties compared to films without treatment.

![Figure 11](image-url). Comparison of strain results of chitosan films without neutralizing (Qs W1) and neutralized films using NaOH and KOH at different concentrations, solubilized with acetic acid at concentrations of (\(\square\)) 1%, (\(\times\)) 0.8%, (\(\backslash\)) 0.5%.
Figure 12. SEM of chitosan films without neutralizing process: (A) membrane surface, (B) cross section of fracture.

Figure 13. SEM by chitosan films surface solubilize with acetic acid 1% (A) and (C) and 0.5% (B) and (D); neutralized with NaOH 0.5 M (A) and (B) and KOH 0.5 M (C) and (D).
4. Conclusions

The neutralization process of chitosan polycation to pH 6.0 by the drip method of bases did not show precipitation of chitosan. Additionally, different concentrations of acetic acid did not present significant difference to the physicochemical properties of chitosan membranes.

The use of strong bases such as NaOH and KOH caused several changes to the membrane (conformity of crystals, increase in the thickness, high capacity to retain moisture and variation in the mechanical properties of the films). These results from the methodology were used in the neutralization of the chitosan polycation, which allowed for the creation of membranes with favorable characteristics for the development of matrices for biosensors or load cells, due to the presence of sodium or potassium ions in the polymer structure.

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